

ICS 31.2
CCS L 90



**NATIONAL STANDARD OF THE
PEOPLE'S REPUBLIC OF CHINA**

GB/T 16527-1996

**Specification for photoresist/E-beam resist for hard surface
photoplates**

(English Translation)

Issued on: September 9, 1996

Implemented on: May 1, 1997

Issued by: State Bureau of Technical Supervision

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What this standard covers

This standard specifies the hard surface of the photosensitive plate photoresists and electron beam resist coating requirements, test methods and so on. This standard applies to the hard surface of the photosensitive plate photoresists and electron beam resist coating inspection.

Document data

International classification (ICS): 31.2.

Chinese classification (CCS): L90.

Estimated length of the Chinese original: 6,617 words.

Adopted international standard: SEMI P3-1990, MOD.

Standards quoted by this document

GB 191-1990; GB 2828-1987; GB 2829-1987; GB 7238-1987; GB 7239-1987; GB/T 15871-1995; GB/T 15870-1995; SJ/T 10584-1994